

The ELENA Electron Cooler; Parameter Choice and Expected

ABSTRACT

Electron cooling will be central to the success of the ELENA project which aims to increase by a factor of up to 100 the number of antiprotons available for the trap experiments. Because of the tight space constraints, the design of the device will be based on the compact electron cooler in operation on the S-LSR ring in Kyoto.

The biggest challenge will be to generate a cold and stable electron beam at an energy of just 55 eV in order to cool the 100 keV antiprotons. The use of photocathodes is excluded because their relatively short lifetime would require too many vacuum interventions during operation. We present the design parameters of our cooler as well as the results of the cooling performance simulations made with BetaCool

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Performance

Cooling will be needed at two momenta during the ELENA deceleration cycle. At the intermediate momentum of 35 MeV/c the antiproton beam will need to be cooled in order to guarantee that it can be decelerated further to 13.7 MeV/c without any excessive blowup of the beam dimensions which could lead to beam loss. At the lower momentum the cooling will ensure that the phase-space characteristics of the extracted antiproton beam fit the requirements of the experiments.



The S-LSR cooler at Kyoto Uni.



WEPPO16



and on-going work into "cold" cathodes.

Main Parameters of the Electron Cooler

Momentum (MeV/c)	35	13.7
β	0.037	0.015
Electron beam energy (eV)	355	55
Electron current (mA)	5	2
Electron beam density (m ⁻³)	1.38×10^{12}	1.41×10^{12}
Bgun (G)	100	00
Bdrift (G)	10	0
Expansion factor (desired)	10)
Cathode radius (mm)	8	
Electron beam radius (mm)	25	
Length of cooling section (m)	1	
Total cooler length (m)	1.9	3
Twiss parameters (m)	β _h =2.103, β _v =2.	186, D=1.498



Schedule:

2013 Negotiations with Toshiba, update design
2014-07/2015 Contruction, tests and delivery to CERN
2015 Vacuum preparation, magnetic field correction
2016 Installation on ELENA, first cooling with p/H⁻



The cooler will be installed in long straight section 4 of the machine and will take up almost half the available space. It will be based on the compact electron cooler built by Toshiba Corp for the S-LSR ring in Kyoto. The rest of the section will accommodate the orbit correctors and the compensation solenoids of the cooler..

Differences w.r.t. the S-LSR cooler

XHV compatibility, NEG coating Device will be installed horizontally Lower electron energy, < 355 eV Lower B field (100G) in cooling region Expansion factor of 10

Preliminary results of cooling simulations with BetaCool

Cooling @ 35 MeV/c •Initial beam parameters: $e_{h,v} = 50 \text{ p mm mrad}$, $DP/P = \pm 2 \times 10^{-3}$

•Look at emittances (95% of the distribution) after 8 seconds of cooling

•Check influence of electron beam transverse temperature



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Evol	ution									🎦 Beam
Mo	mentum	Number	Bunch L	uminosity.	Beam-be	eam 3D [Diagram			Emittance
								0.000147		Emittanc (* 1 sig C norm Momentu (* relati C abso V Gam V Equil V Footy
	:	2	Reference	4 e time [sec]		6	1	J B		I Evol I Gaus

🔓 Beam Evolution				
Emittance Momentum 1	Number Bunch L	uminosity Beam-bea	m 3D Diagram	
Emittance	Horizontal Emittance [pi-mm-mrad]			Gamma2 Equilibrium FootPrint Evolution
🔽 Gaussian fit	1E-7	0.000 Momentum Sprea		1

/P (10 ⁻³)



90%	le (mA)	kT (eV)	ε _h (π mm mrad)	ε _v (π mm mrad)	∆P/P (10 ⁻³)
	5	0.1	9.8 (2.7)	9.7 (3)	±0.36
	5	0.03	4.5 (0.4)	5.3 (0.2)	±0.25
	5	0.01	2.4 (0.3)	2.6 (0.01)	±0.23
	10	0.01	5.9 (0.3)	6.8 (0.01)	±0.33

Cooling at 13.7 MeV/c •Initial beam parameters: $e_{h,v} = 15 \text{ p mm mrad}$, $DP/P = \pm 1 \times 10^{-3}$

Cold electron sources

1. Photocathodes

- 2. Electron Generator Array (BURLE Electro-optics)
- 3. Electron multiplier (MCP) illuminated by e.g. photons (Hyun Sik Kim et al.)
- 4. Carbon nanotubes

Microchannel Plates operate on the principle of secondary electron emission. When a charged particle impinges on the input side of the channel with sufficient energy, a few secondary electrons are produced. The resultant electrons continue to cascade down the channel until a charge cloud exits the channel. By altering the microstructure within the channel, spontaneously emitted electrons can be produced, initiating the cascade of secondary electrons. By controlling the rate of spontaneous emission and the gain of the device, the emission current can be varied over a broad range.







•Look at emittances (95% of the distribution) after 2 seconds of cooling





Coordinate

0 0.5 1 1.5 time [sec]





Distribution					
Profile Invariant Evolution Control	le (mA)	kT (eV)	ε _h (μm)	ε _ν (μm)	ΔΡ
	1	0.03	2.4	1.5	±0.
	1	0.01	2.1	1.3	±0.
	2	0.01	1.9	1.1	±0.

Design of the ELENA electron cooler is well advanced

Preliminary studies with BetaCool to determine baseline

Negotiations with Toshiba Corp for the construction

Need to simulate adiabatic capture with electron cooling

Test stand to be built to invetigate the possibility of using a « cold » electron source